

Feature

- High Precision GaAs process
- High performance, shielded
- GaAs substrate, 50Ω CPW output
- Au wire bonding, for MCM applications

Environmental Specifications

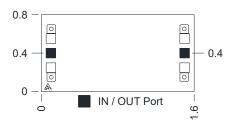
| Operating Temperature | -55℃~+85℃ | |
|-----------------------|--------------|--|
| Storage Temperature | -65°C∼+150°C | |
| Max. Input Power | 30dBm | |

Electrical Specifications($T_A = +25^{\circ}C$)

| Parameter | Min. | Тур. | Max. | Unit |
|---------------------|--------------|------|------|------|
| Cut-off Freq. (f₀) | - | 8 | - | GHz |
| Insertion Loss @ fc | - | - | 1.6 | dB |
| Return Loss | 15 | - | - | dB |
| Out of band | ≥20@12.3GHz | | | dB |
| Attenuation | ≥40@15.55GHz | | dB | |

S2P file name: BWLF-8.s2p

Outline Drawing



Notes:

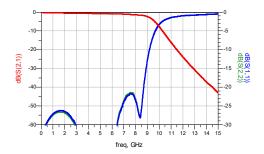
- 1. Dimensions are in millimeters. Tolerance: ±0.05mm
- 2. Die thickness is 0.1mm
- 3. Typical bond pad is 0.1x0.1 mm².
- 4. The bottom of the device is gold plated, should be grounded.

Typical Test Curves

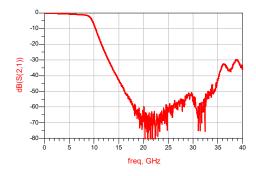
Insertion Loss VS Frequency ($T_A=25^{\circ}C$)



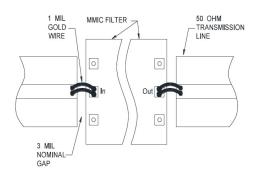
Insertion Loss & Return Loss VS Frequency (T_A=25°C)



Broadband Insertion Loss VS Frequency (T_A=25°C)



Recommended Assembly Diagrams



Application Notes:

- 1. The chip is back-metallized and can be die-mounted with AuSn eutectic preforms or with electrically conductive epoxy.
- 2. The die should be assembled on carriers like Kovar or Mu-Cu which have same Coefficient of thermal expansion. (5.8×10-6/) with GaAs.
- 3. Recommend using $\Phi 25 um$ Au wire for bonding, whose length is around 400 um.
- 4. Sinter by AuSn (80/20), which doesn't exceed 300°C within 30 seconds max.
- 4. Handle the chips in a clean environment. DO NOT attempt to clean the chip using liquid cleaning systems.
- 5. Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers.
- 6. The device is sensitive to ESD. ESD protection is required during storage and usage.
- 7. If you have any questions, please contact us.